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(54) Title: ELECTROPLATING COMPOSITION AND METHOD FOR ELECTROPLATING A CHROMIUM COATING ON A SUBSTRATE

(57) Abstract: The present invention refers to an electroplating composition for plating a chromium coating on a substrate, the composition comprising: (i) a source of hexavalent chromium; (ii) one or more than one betaine comprising a quaternary nitrogen and/or salts thereof; and (iii) one or more than one poly-organosiloxane.



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